

**Claims:**

This listing of claims are as presented in the Amendment of October 19, 2006 and no amendments have been made herein:

**Listing of Claims:**

Claim 1 (original) A method of fabricating an optoelectronic device, comprising:  
depositing a first layer over a first electrode by organic vapor phase deposition, wherein the first layer comprises a first organic small molecule material;  
depositing a second layer on the first layer such that the second layer is in physical contact with the first layer, wherein the interface of the second layer on the first layer forms a bulk heterojunction; and  
depositing a second electrode over the second layer to form the optoelectronic device.

Claim 2 (original) The method of claim 1, wherein the first layer is an electron donor layer, the first electrode is an anode, the second layer is an electron acceptor layer, and the second electrode is a cathode.

Claim 3 (original) The method of claim 1, wherein the first layer is an electron acceptor layer, the first electrode is a cathode, the second layer is an electron donor layer, and the second electrode is an anode.

Claim 4 (previously presented) The method of claim 1, wherein the first layer has a surface area-to-volume ratio of at least 2:1, wherein the surface area and volume are measured in micrometers.

Claim 5 (previously presented) The method of claim 4, wherein the first layer has a surface area-to-volume ratio of at least 5:1, wherein the surface area and volume are measured in micrometers.

Claim 6 (original) The method of claim 1, wherein the second layer comprises a second organic small molecule material and is deposited by organic vapor phase deposition, wherein the organic vapor phase deposition of the first and second layers occurs at an underlying substrate temperature in the range of about 0° to about 100°C, and at a deposition chamber pressure in the range of about 50 mTorr to about 10 Torr.

Claim 7 (original) The method of claim 6, wherein the first electrode comprises ITO, the first layer comprises CuPc, and the second layer comprises PTCBI.

Claim 8 (original) The method of claim 6, wherein the first electrode comprises ITO, the first layer comprises CuPc, and the second layer comprises C<sub>60</sub>.

Claim 9 (original) The method of claim 1, wherein the cohesive energy of the first organic small molecule material is such that the first organic small molecule material tends to adhere to itself rather than an underlying substrate.

Claim 10 (original) The method of claim 1, further comprising:  
depositing the first layer over a substrate.

Claim 11 (original) The method of claim 10, wherein the substrate comprises plastic.

Claim 12 (original) The method of claim 2, further comprising:  
depositing an exciton blocking layer over the second layer, such that the second electrode is deposited over the exciton blocking layer.

Claim 13 (original) The method of claim 12, wherein the exciton blocking layer is deposited by organic vapor phase deposition, and comprises BCP.

Claim 14 (original) The method of claim 1, further comprising:

depositing a wetting layer over the first electrode, such that the first layer is deposited over the wetting layer; and

depositing a planarizing layer over the second layer, such that the second electrode is deposited over the planarizing layer.

Claim 15 (original) The method of claim 14, wherein the wetting layer and the planarizing layer are deposited by organic vapor phase deposition.

Claim 16 (original) The method of claim 15, wherein the planarizing layer comprises PEDOT:PSS, and the wetting layer comprises PEDOT:PSS.

Claim 17 (original) A method of fabricating an optoelectronic device, comprising:

depositing a first layer having protrusions over a first electrode, wherein the first layer comprises a first organic small molecule material;

depositing a second layer on the first layer such that the second layer is in physical contact with the first layer, wherein the interface of the second layer on the first layer forms a bulk heterojunction; and

depositing a second electrode over the second layer to form the optoelectronic device.

Claim 18 (original) The method of claim 17, wherein the first layer is an electron donor layer, the first electrode is an anode, the second layer is an electron acceptor layer, and the second electrode is a cathode.

Claim 19 (original) The method of claim 17, wherein the first layer is an electron acceptor layer, the first electrode is a cathode, the second layer is an electron donor layer, and the second electrode is an anode.

Claim 20 (original) The method of claim 17, wherein the diameter of the protrusions are between 1 to 5 times the exciton diffusion length of the first organic small molecule material.

Claim 21 (original) The method of claim 20, wherein the diameter of the protrusions are between 1.5 to 3 times the exciton diffusion length of the first organic small molecule material.

Claim 22 (original) The method of claim 18, wherein the first electrode comprises ITO, the first layer comprises CuPc, and the second layer comprises PTCBI.

Claim 23 (original) The method of claim 18, wherein the first electrode comprises ITO, the first layer comprises CuPc, and the second layer comprises C<sub>60</sub>.

Claim 24 (original) The method of claim 17, wherein the cohesive energy of the first organic small molecule material is such that the first organic small molecule material tends to adhere to itself rather than an underlying substrate.

Claim 25 (original) The method of claim 17, further comprising:  
depositing the first layer over a substrate.

Claim 26 (original) The method of claim 25, wherein the substrate comprises plastic.

Claim 27 (original) The method of claim 18, further comprising:  
depositing an exciton blocking layer over the second layer, such that the second electrode is deposited over the exciton blocking layer.

Claim 28 (original) The method of claim 27, wherein the exciton blocking layer comprises BCP.

Claim 29 (original) The method of claim 17, further comprising:

depositing a wetting layer over the first electrode, such that the first layer is deposited over the wetting layer; and

depositing a planarizing layer over the second layer, such that the second electrode is deposited over the planarizing layer.

Claim 30 (original) The method of claim 29, wherein the planarizing layer comprises PEDOT:PSS, and the wetting layer comprises PEDOT:PSS.

Claim 31 (original) The method of claim 1, further comprising:

depositing an electron-hole recombination zone over the second layer;

depositing a third layer over the electron-hole recombination zone by organic vapor phase deposition, wherein the third layer comprises a third organic small molecule material;

depositing a fourth layer on the third layer such that the fourth layer is in physical contact with the third layer, wherein the interface of the fourth layer on the third layer forms a bulk heterojunction; and

depositing the second electrode over the fourth layer to form the optoelectronic device.

Claim 32 (original) The method of claim 17, further comprising:

depositing an electron-hole recombination zone over the second layer;

depositing a third layer having protrusions over the electron-hole recombination zone, wherein the third layer comprises a third organic small molecule material;

depositing a fourth layer on the third layer such that the fourth layer is in physical contact with the third layer, wherein the interface of the fourth layer on the third layer forms a bulk heterojunction; and

depositing the second electrode over the fourth layer to form the optoelectronic device.

Claim 33 (original) A method of forming a bulk heterojunction comprising:  
depositing a first layer over a substrate by organic vapor phase deposition,  
wherein the first layer comprises a first organic small molecule material; and  
depositing a second layer on the first layer such that the second layer is in  
physical contact with the first layer, wherein the interface of the second layer on the  
first layer forms a bulk heterojunction.

Claim 34 (original) A method of forming a bulk heterojunction comprising:  
depositing a first layer having protrusions over a substrate, wherein the first  
layer comprises a first organic small molecule material; and  
depositing a second layer on the first layer such that the second layer is in  
physical contact with the first layer, wherein the interface of the second layer on the  
first layer forms a bulk heterojunction.